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M. Boselli • M. Gherardi • V. Colombo,

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3D modelling of the synthesis of copper nanoparticles by means of a DC transferred arc twin torch plasma system

M. Boselli • M. Gherardi • V. Colombo

Alma Mater Studiorum-Università di Bologna, Department of Industrial Engineering, Viale del Risorgimento 2, 40136 Bologna, Italy

Abstract An atmospheric pressure DC transferred arc twin torch thermal plasma system has been characterized by 3D simulation in order to assess its potential for the synthesis of Cu nanoparticles from solid precursors. The numerical model also takes into account the non-negligible effect on process temperature of radiative losses, transport and thermodynamic properties of Cu vapour. In the frame of design-oriented simulation and optimization of the synthesis process, mean diameter and yield of the synthesized nanoparticles have been investigated for different current levels, gas flow rates, precursor feed rates and nanoparticles model. Results show that evaporation efficiency is considerably high even at precursor feed rates up to 25 kg/day, while the presence of vortices inside the chambers causes a significative loss of nanoparticles to the reactor walls, with a detrimental effect to the yield.

1. Introduction

Thermal plasmas [1-3], especially radio-frequency induction thermal plasmas (RF-ITP), are effective tools for continuous nanoparticles synthesis at high throughput. The working principle consists in injecting a solid or liquid precursor inside the plasma region, where it melts (if solid, like in the case of this work) and evaporates due to high temperatures (commonly, 8000 K at least in all thermal plasma systems). The vaporized material then becomes supersaturated due to the characteristically steep cooling encountered in the fringes of the plasma region and nucleation occurs; these nuclei then grow because of condensation and coagulation. However, as the process is characterized by a large number of variables,

optimization is a challenging task, that often cannot rely on experimental try and fail approaches, due to high equipment cost and the limited amount of data that can be obtained from experimental diagnostic techniques. For this reason, the investigation of the performance of thermal plasmas processes for nanoparticle synthesis has relied extensively on modelling techniques [4-10].

The performance of the process can be evaluated by the yield and by the fraction of the injected precursor that is effectively evaporated in the plasma (precursor evaporation efficiency). Precursor dimensions and feed rate strongly influence precursor evaporation efficiency: in the region where the material is injected the plasma is affected by a local cooling caused by precursor feed rates, possibly with detrimental effect on the precursor heating (*loading effect*) [11]. The evaporation efficiency is also limited by the radiative power loss coming from the vapour present in the plasma. Most metal vapours have high emissivity and significantly reduce the precursor evaporation efficiency [12-14].

Quench gas injection is perhaps the optimization parameter most thoroughly investigated, because it impacts strongly on flow fields, temperature distribution and cooling rates in the system [15-18]. The cooling rate that can be generated by the quench gas allows for the synthesis of nanoparticles with a narrow Particle Size Distribution (PSD). Additionally, the type and position of the quenching injection, together with the geometry of the reaction chamber, have been shown to affect the properties and the production rate of the synthesized nanoparticles [11, 19-20]. Quench gas injection operates with several hundreds of standard litres per minute of inert gas, usually Ar.

DC transferred arc twin torch plasma systems are devices consisting of two electrodes generating a plasma arc sustained by means of an electric current flowing through the body of the discharge; this plasma arc is typically characterized by a very high temperature (20-30 kK) [21] and operating power usually in the 0.2-2.4 MW range, which could provide at high precursor feed rates an higher evaporation rate compared to RF-ITP systems. Twin torches are intrinsically asymmetrical systems, with cathodic and anodic electrodes having their axes tilted with respect to the vertical; the discharge generated by this particular plasma source configuration is characterized by a complex shape and fluid dynamic behaviour and a 3D description is needed in order to realistically predict it. 3D models have been previously used to study temperature and velocity distribution of such devices with local thermodynamic equilibrium (LTE) assumption [22-25] or even assuming non-LTE [24]. Compared to RF-ITP [1-4,6,8-9], few papers have been published on twin torch plasma systems [22-25], possibly due to the heavy computational load required for 3D plasma modelling, and, in the author's experience, no papers have been published on modelling of nanoparticle synthesis process by twin torch plasma systems.

In this paper we present a static 3D LTE model for the synthesis of Cu nanoparticles in Ar plasma by evaporation of micrometric solid Cu precursors in a twin torch plasma system. This work has been performed in the frame of the Horizon 2020 "INDustrial Scale Production of Innovative nanomaterials for printed Devices" (INSPIRED) project for the scale up of Cu nanoparticles synthesis to appropriate industrial scale quantities (more than 20 kg/day of throughput).

This paper can be of some help in evaluating the potentialities of nanoparticle synthesis with a twin torch plasma system, such as process control and efficiencies as well as technical requirements, such as the design of the reaction chamber and quenching gas injection, as well as sizing for gas recycling systems to manage the conspicuous quenching gas consumption. Even if twin torch systems are being

commercialized on the market also for the purpose of nano-synthesis of materials, a deep understanding of this topic is still neglected in literature; especially when compared to the abundant number of works on RF-ITP nano-synthesis.

2. Modelling approach

The nanoparticle synthesis process, including plasma thermo-fluid dynamics, electromagnetic field, precursor injection and evaporation, and nanoparticle formation, transport and growth, is modelled in the ANSYS FLUENT© environment [26], within a 3D framework. The employed models describe plasma thermo-fluid-dynamics, electromagnetic field, precursor behaviour (injection, trajectories, thermal history and evaporation) and nanoparticle formation, transport and growth.

2.1 Plasma modelling

The governing equations and assumptions for plasma thermo-fluid-dynamics calculations are described in [13]. The equations have been properly implemented in a 3D environment, moreover, not only the effect of Cu vapour on radiative losses of the gas mixture, but also on the transport and thermodynamic properties is considered.

Plasma thermodynamic and transport properties for Ar and Cu (specifically for Cu, electrical conductivity, density, viscosity and thermal conductivity) in LTE have been computed as in [27]. In calculating the radiative losses, the contributions from both Ar and Cu vapour are taken into account, using data from [28]. The volumetric radiative loss was obtained by linear interpolation of the Net Emission Coefficients (NEC) based on the molar fractions of Ar and Cu vapour, as suggested by Gleizes et al. [29].

The Lorentz force, $\mathbf{F}_L$, and Joule dissipation, P_J , can be expressed as:

$$\mathbf{F}_L = \mathbf{J} \times \mathbf{B} \quad (1)$$

$$P_J = \mathbf{J} \cdot \mathbf{E} \quad (2)$$

where $\mathbf{B}$ and $\mathbf{E}$ are the magnetic and electric field respectively and $\mathbf{J}$ is the current density.

The electromagnetic field is calculated using Maxwell's equations written explicitly for the vector potential $\mathbf{A}$ and scalar potential V . The vector and scalar potential equations are solved in the following form:

$$\nabla^2 \mathbf{A} - \mu_0 \sigma \mathbf{E} = 0 \quad (3)$$

$$\nabla \cdot (\sigma \nabla V) = 0 \quad (4)$$

where σ is the electrical conductivity; the electric field is related to the gradient of the scalar potential ($\mathbf{E} = -\nabla V$) and the current density has been calculated using the simplified Ohm's law, neglecting the Hall current $\mathbf{J} = \sigma \mathbf{E}$.

The precursor model adopts the assumptions and equations presented in [30].

2.2 The nanoparticle synthesis model

In this paper two different models have been adopted for nanoparticle synthesis: the method of the moments and the nodal model. The method of moments equations have been described in [13], as well as the assumptions for both the models.

In the nodal model a logarithmic scale linear discretization of the PSD function is employed, as proposed by [6,31]:

$$v_{p_{n+1}} = \lambda v_{p_n} \quad n = 0, 1, \dots, n_{max} \quad (5)$$

where v_p the particle volume, λ is the geometric spacing factor, fixed at 1.6 and n_{max} , the number of nodes, is 42.

The value of v_{p_0} , is defined in order to obtain a discretized PSD covering the entire range of particles produced; v_{p_0} is considered ten times the volume of the Cu monomer, v_1 .

Therefore, the discretized aerosol general dynamic equation for the particle distribution N_p at node n , considering turbulent effects, takes the following form:

$$\nabla \cdot (\mathbf{u} N_{p_n}) = \nabla \cdot (D_{p_n}^{tot} \nabla N_{p_n}) + (\dot{N}_{p_n})^{nucl} + (\dot{N}_{p_n})^{cond} + (\dot{N}_{p_n})^{coag} \quad (6)$$

Where $\mathbf{u}$ is the velocity vector, N_{p_n} is the particle concentration at node n , $D_{p_n}^{tot}$ the total diffusion coefficient for particles at node n , $(\dot{N}_{p_n})^{nucl}$ the nucleation source term, $(\dot{N}_{p_n})^{cond}$ the condensation source term and $(\dot{N}_{p_n})^{coag}$ the coagulation net production rate. The net production rate at node n by nucleation is defined as:

$$(\dot{N}_{p_n})^{nucl} = I \xi_n^{nucl} \quad (7)$$

Where I is the nucleation rate, as proposed in [32] and ξ_n^{nucl} is the nucleation size operator, introduced to distribute the nanoparticles generated at volume v^* in the proper node:

$$\xi_n^{nucl} = \begin{cases} \frac{v^*}{v_{p_j}} & \text{if } (v_{p_{j-1}} < v^* < v_{p_j}) \\ \frac{v^*}{v_1} & \text{if } (v^* < v_1) \\ 0 & \text{otherwise} \end{cases} \quad (8)$$

Where v_{p_j} is the volume of the particle corresponding to the j^{th} node.

The condensation source term for the node n is defined as:

$$(\dot{N}_{p_n})^{cond} = \sum_j \frac{(\xi_{jn}^{cond} - \delta_{jn}) N_{p_j}}{\Delta t} \quad (9)$$

where Δt is the condensation time lag, δ_{jn} the Kroenecker delta and ξ_{jn}^{cond} the size splitting operator graphically and defined as:

$$\xi_{jn}^{cond} = \begin{cases} \frac{v_{p_{n+1}} - (v_{p_j} + \Delta v_{p_j})}{v_{p_{n+1}} - v_{p_n}} & \text{if } (v_{p_n} < v_{p_j} + \Delta v_{p_j} < v_{p_{n+1}}) \\ \frac{(v_{p_j} + \Delta v_{p_j}) - v_{p_{n-1}}}{v_{p_n} - v_{p_{n-1}}} & \text{if } (v_{p_{n-1}} < v_{p_j} + \Delta v_{p_j} < v_{p_n}) \\ 0 & \text{otherwise} \end{cases} \quad (10)$$

Where the volume increment of each particle due to condensation is determined by [33]:

$$\frac{dv_{p_j}}{dt} = 2\pi d_{p_j} D_{vap}^L v_1 (n_1 - n'_{s_j}) \left(\frac{0.75\alpha(1 + Kn_j)}{0.75\alpha + 0.283\alpha Kn_j + Kn_j + Kn_j^2} \right) \quad (11)$$

where n_1 is the vapour concentration, n'_{s_j} is the vapour concentration at saturation considering the Kelvin effect for the vapour interacting with the j^{th} node particle and α is the condensation accommodation coefficient, whose value ranges from 0.013 to 0.38, according to [34]; here a value of 0.05 is used, as proposed in [17].

The coagulation source term is expressed by Smoluchowski's equation [35], where every time a particle of volume v_{p_i} collides with a particle of volume v_{p_j} , a coagulated particle of volume $v_{p_i} + v_{p_j}$ is formed:

$$(\dot{N}_{p_n})^{coag} = \frac{1}{2} \sum_i \sum_j \xi_{ijn}^{coag} \beta_{ij} N_{p_i} N_{p_j} - N_{p_n} \sum_i \beta_{in} N_{p_i} \quad (12)$$

Where subscripts i and j denote the nodes to which the colliding particles belong and ξ_{ijn}^{coag} is the coagulation size splitting operator and defined as:

$$\xi_{ijn}^{coag} = \begin{cases} \frac{v_{p_{n+1}} - (v_{p_i} + v_{p_j})}{v_{p_{n+1}} - v_{p_n}} & \text{if } (v_{p_n} < v_{p_i} + v_{p_j} < v_{p_{n+1}}) \\ \frac{(v_{p_i} + v_{p_j}) - v_{p_{n-1}}}{v_{p_n} - v_{p_{n-1}}} & \text{if } (v_{p_{n-1}} < (v_{p_i} + v_{p_j}) < v_{p_n}) \\ 0 & \text{otherwise} \end{cases} \quad (13)$$

While β_{ij} is the collision frequency proposed by [28] to cover wide particle size ranges.

2.3 Material properties

The physical properties for Cu powders are reported in Table 1 and were taken from [36-37]. Micro-sized Cu precursor particles are injected through the probe by means of the Ar carrier gas with different feed rates spanning from 0.23 kg/h to 4 kg/h and were assumed to have a Rosin-Rammler distribution with mean diameter of 7.3 μm .

Table 1 Physical properties for Cu powders

Property	Units	Value
ρ_p	kg m^{-3}	8900
c_p	$\text{J kg}^{-1} \text{K}^{-1}$	385
λ_m	J kg^{-1}	2.05×10^5
λ_v	J kg^{-1}	4.74×10^6
T_m	K	$1357.6 - 2.55 \times 10^6 d_p^{-1}$
T_v	K	2385
$\varepsilon_{\text{sol.}}$	adm	0.6
$\varepsilon_{\text{liq.}}$	adm	0.3
k_p	$\text{W m}^{-1} \text{K}^{-1}$	320
M	g mol^{-1}	63.546
R_0	nm	0.135
γ	N m^{-1}	$1.257 - 2 \times 10^{-4} (T - 1356)$
p_{sat}	Pa	$10^{(10.855 - 16415 T^{-1})}$

2.5 Computational domain and boundary conditions

Figure 1 Schematic of the twin torch reactor geometry

The twin torch reactor geometry is reported in Figure 1. The synthesis process occurs inside a reaction chamber, with precursors fed vertically along its axis with a carrier gas. The anode is a water-cooled copper electrode, while the cathode is a graphite electrode. The precursors are vaporized by interaction with the plasma arc and nanoparticles are synthesized in the reaction chamber by interaction with a quenching gas flow. An additional sweep gas flow is fed from the top of the reaction chamber to shield its walls from the plasma. There are two sections for the injection of the quench gas in the reaction chamber. The quench gas is injected almost parallel to the axis of the reaction chamber. In a twin torch system the strong local cooling of the plasma near the region where the material is injected and evaporated due to radiative power losses can affect the behaviour of the arc. A computational mesh of 3.8 million of polyhedral elements has been used and it is represented in Figure 2.

Figure 2 Complete computational mesh of the reaction chamber (left) and detail of the mesh in the inter-electrode and plasma discharge region (right).

Electrodes' interfaces are considered using a simplified approach, imposing a current density distribution on the cathode surface and a zero-voltage potential on the anode [8]. Temperatures on the surfaces of the anode and the cathode are assumed to be respectively 2000 and 3000 K.

A no-slip boundary condition is applied on all the internal walls; boundary conditions for turbulence equations at the torch inlet are set according to Chen et al. [38]. A temperature of 300 K is fixed at the internal walls of the reaction chambers, corresponding to a water-cooled system. The operating pressure is set to 100 kPa.

3. Results and discussion

Results of plasma temperature distribution, vectors of velocity, evaporation efficiency, mean diameter and yield will be presented in this section, for two levels of operating current and precursors feed rates between 5 and 24 kg/day. Also nodal model results will be compared to method of moments one. This investigation is aimed to assess the industrial sustainability of a twin torch plasma system for the synthesis of Cu nanoparticles.

With an operative current of 1200 A and a precursor feed rate of 0.25 kg/h, by neglecting in the model the effect of radiative losses from Cu, the gas temperature is higher than 6000 K up to several centimetres downstream the attachment of the two arc columns, as shown in the top part of Figure 3. The heat exchange with the precursors is almost negligible due to the low mass flow rate of precursors, and the evaporation efficiency is 100 %. As it is shown in the bottom part of Figure 3, the temperature drops down abruptly by considering Cu vapor properties. Still, the evaporation efficiency is almost complete (97%), as most of the Cu particles cross the electric arc region, where they can reach easily their boiling temperature (2835 K), as shown in Figure 4.

Figure 3 Temperature isosurfaces for the case at 1200 A and a precursor feed rate of 0.25 kg/h, calculated neglecting the effect of Cu vapour properties (top) and considering them (bottom).

Figure 4 Precursors pathlines and thermal history for the case at 1200 A and a precursor feed rate of 0.25 kg/h

In Figure 5 velocity field vectors are reported for the reaction chamber region. The effect of the complex interaction between the two plasma columns and the quenching injection zone is highlighted: simulations results show that the twin torch system is particularly difficult to set in terms of operating conditions that would favour the synthesis of nanoparticles; to properly quench the high temperature plasma outflow is a challenging task. For example, if the operative current is set to 1200 A and the precursor feed rate at 0.25 kg/h, even with 1000 slpm of quench gas fed through several injections at different axial positions in the reaction chamber, the effluent temperature is so high that most of the produced Cu vapours are yet not converted to nanoparticles; the too small amount of them that has been synthesized shows a mean diameter of 14 nm (Table 2). The process yield is defined as the ratio between the total nanoparticle throughput and the precursor feed rate. Nanoparticles are synthesized where the quench gas cools down the hot gas coming from the electrode region, as shown in Figure 6, with a yield of 10 % (Table 2).

Figure 5 Vector velocity fields for the case at 1200 A and a precursor feed rate of 0.25 kg/h, considering the radiative losses of Cu vapour. The blue arrows represent the quench gas injection section.

Table 2. Summary of the performances of the synthesis process at 1200 and 520 A of operating current, with a precursor feed rate of 0.25 kg/h and 1000 slpm of quench gas. Mean diameter and yield of the synthesized nanoparticles obtained with method of moments.

Current (A)	Evaporation efficiency (%)	Yield (%)	$\bar{d}_p$ at outlet (nm)
1200	97%	10%	14
520	68%	6%	22

Figure 6 Vapour consumption for the case at 1200 A and a precursor feed rate of 0.25 kg/h, considering the radiative losses of Cu vapour. The blue arrows represent the quench gas injection sections.

At 520 A of operating current (Figure 7) the evaporation efficiency is close to 70% up to 24 kg/day of precursor feed rate (Figure 8). The experimental evaporation rate at 520 A was estimated by weighting the material collected in the reaction chamber and chamber walls. The total amount of collected Cu was 2.2 kg. The amount of precursor injected in the system was 6.7 kg with a feed rate of 9.1 kg/day. Thus, 4.5 kg of precursor were evaporated corresponding to an evaporation efficiency of 67.16%. This value is in good agreement with the output from simulation (66,5%) for the same operating condition.

Figure 7 Temperature isosurfaces for the case at 520 A and a precursor feed rate of 0.25 kg/h

Figure 8 Evaporation efficiency at 520 A

Results of the Cu nanoparticles distribution obtained using the method of moments are shown in Figure 9. Nanoparticles are lost in the chamber by wall deposition. With a complete downwards flow, growth

mechanisms like condensation and coagulation should increase mean particle size along the reaction chamber with a unidirectional downwards flow. Vortices instead bring back upwards nanoparticles, increasing their size.

Errore. L'origine riferimento non è stata trovata.

Figure 9 Nanoparticles concentration and mean diameter in the reaction chamber with the method of moments, on the right, for the case at 520 A and a precursor feed rate of 1 kg/h. On the left, vectors of upwards velocity, showing the presence of vortices in the chamber.

Nodal model results for the same operating condition are shown in Figure 10, where nanoparticles seem to concentrate in the region above the top vortex. The mean diameter distribution of the nanoparticles is much different with respect of the one obtainable through the method of moments, even though they have similar values (25 nm vs 22 nm) characterize the outlet region.

The smallest nanoparticles (V_0) are mainly nucleated in the region above the top vortex. The particles which avoid deposition on the walls of the reaction chamber grow mainly in an intermediate dimensional range, while just a few “large” particles (diameter higher than 100 nm) can be found at the outlet. In terms of results the two models have comparable values for the mean particle size at the outlet. The nodal model predicts a lower yield than the method of moments. Therefore, experimental results (not shown in this paper) on yield suggests that, at least for this operating condition, the method of moments produces a more reliable output. Considering that the nodal model didn’t show any bimodal distribution and it has a quite intense computational load for a 3d geometry, it is advisable to investigate the optimum operating conditions by the method of moments, followed by a verification by the nodal model of the expected PSD just for a few selected operating conditions.

Figure 10 Nanoparticles concentration and mean diameter in the reaction chamber with the nodal method, on the left, for the case at 520 A and a precursor feed rate of 1 kg/h. On the right, nanoparticles concentrations for 4 node volumes of different sizes (respectively 0.9, 7, 53 and 403 nm).

4. Conclusions

This work has been performed in the frame of the Horizon 2020 INSPIRED project for the scale up of Cu nanoparticles synthesis to appropriate industrial scale quantities (more than 20 kg/day of throughput). To assess the feasibility of this task and to seek an optimum route, a 3D thermo-fluid-dynamic model was employed to simulate the Cu nanoparticle synthesis process by a DC twin torch thermal plasma system. The developed model considers Cu vapour thermodynamic and transport properties.

The effect of different precursor flow rates, operative current and quench gas flow rates on the synthesized nanoparticles mean diameter and yield have been investigated. The adopted simulative model can describe plasma thermo-fluid dynamics, electromagnetic fields, precursor trajectories and thermal history and nanoparticle nucleation and growth. Cu vapour thermodynamic and transport properties have also been considered in the model. While evaporation efficiency is considerably high even at precursor feed rates up to 25 kg/day, the presence of vortices inside the chambers causes a significative loss of nanoparticles to the reactor walls, with a detrimental effect to the yield, which is almost an order of

magnitude lower than the one obtainable by an RF-ITP system (50-70%) [18]. In the frame of design-oriented modelling, the developed models would serve as a useful tool to make the synthesis process more industrially sustainable, also by optimizing reaction chambers to minimize this loss effect and to improve sensibly the yield. The use of a quenching gas can generate vortices which can quite negatively affect the yield. The optimization of this process is not trivial: it depends on the material to be synthesized and can be investigated by consistently changing the geometry of the reaction chamber, as well as quench gas injection sections, if technically and financially feasible; otherwise optimization can still be investigated operating only on the values of the different gas inputs involved in this complex system.

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